

Photoluminescence studies of lateral composition modulated short-period AlAs/InAs superlattices

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Abstract

We present low temperature photoluminescence data for a series of layers exhibiting spontaneous lateral composition modulation in $(\text{AlAs})_m(\text{InAs})_n$ short period superlattices grown on InP with differing average lattice constants, i.e. varying global strain. The low temperature photoluminescence peak energies were found to be much lower than the corresponding energy expected for the equivalent $\text{In}_x\text{Al}_{1-x}\text{As}$ alloys. The bandgap energy reductions are found to approach 500 meV and this reduction is found to be correlated with the ‘strength’ of the composition modulation wave amplitude. © 1999 Elsevier Science S.A. All rights reserved.

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1. Introduction

Spontaneous lateral composition modulation (CM) resulting from the deposition of short period superlattices (SPS) is a relatively new phenomenon. Recently, a review for the formation and status of CM was presented by Mirecki Millunchick, et al. [1]. Lateral CM in short period superlattices has been observed for a variety of material systems such as $(\text{InP})_m/(\text{GaP})_n$ on GaAs [2,3], $(\text{InAs})_m/(\text{GaAs})_n$ on InP [4,5], and $(\text{AlAs})_m/(\text{InAs})_n$ on InP [6–11]. Here m and n are the number of monolayers (ML) of each binary compound deposited. For these materials and growth conditions, the lateral CM wave is observed along the [110] direction although deviations of this rule have recently been reported [10,11].

In this work, we will present low temperature photoluminescence (PL) data for a series of $(\text{AlAs})_m(\text{InAs})_n$ SPS samples on InP with differing average lattice constants, i.e. varying global strain. Lattice constant variation was achieved by changing the ratio of the layer-thickness of InAs compared to AlAs and at the same time, constraining the superlattice period to range between about 2.5 and 4 monolayers. In this manner, the global strain in the short

period superlattice could be adjusted from tensile to compressive. The low temperature PL peak energies are found to be much lower than the corresponding bandgap energy expected for the concentration equivalent InAlAs alloy. These bandgap energy reductions approach 500 meV and are found to vary as the ‘strength’ of the composition modulation wave amplitude as measured by X-ray diffraction.

The $(\text{AlAs})_m(\text{InAs})_n$ SPS were grown by molecular beam epitaxy techniques on (001) InP at 530°C under As-rich conditions. A buffer layer of approximately lattice matched, random alloy InAlAs was deposited on the InP substrate. The buffer was grown at 0.7 ML/s, while the individual SPS layers were grown at approximately one-half this rate. The growth rates were calibrated in situ using reflection high-energy electron diffraction oscillations. The $(\text{InAs})_n/(\text{AlAs})_m$ SPS with $n + m$ ranging between 1.5 and 4 was deposited on top of the InAlAs buffer. Nominally, 150-period SPS structures were grown. Finally, a thin cap layer of undoped $\text{In}_{0.53}\text{Ga}_{0.47}\text{As}$ was added to the top of the SPS to prevent oxidation of the AlAs layers. The composition and strain of the buffer and SPS were also determined with lattice spacings from X-ray diffraction. In assessing the average strain of the SPS, we assumed that its composite elastic properties are like those of a random alloy, and then used the measured out-of-plane strain to deduce the average in-plane strain and layer composition. Here, strain is defined

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Table 1
Properties for $(\text{AlAs})_m/(\text{InAs})_n$ SPS specimens

Sample (No.)	N (ML)	M (ML)	X-ray intensity (arb. units)	Indium (X)	Strain: E -parallel (%)	PL energy (meV)
EA0117	1.67	2.10	18.2	0.442	+ 0.538	1293.2
EA0118	1.91	2.15	65.5	0.470	+ 0.346	1100.9
EA0119	1.87	1.96	55.7	0.488	+ 0.221	1049.6
EA0120	2.06	1.83	67.3	0.529	– 0.052	1010.1
EA0121	1.60	2.18	0	0.422	+ 0.673	1540.2
EA0122	1.85	2.13	66.6	0.466	+ 0.368	1099.6
EA0147	1.87	1.75	69.6	0.518	+ 0.016	1040.8
EA0149	1.79	1.51	49.0	0.543	– 0.148	1070.0
EA0150	1.78	1.34	50.0	0.571	– 0.338	1053.0
EA0151	1.69	1.17	42.6	0.590	– 0.465	1060.8
EA0168	1.69	2.00	43.2	0.458	+ 0.425	1145.4
EA0180	1.65	0.96	0	0.631	– 0.707	981.8
EA0184	1.98	1.95	60.637	0.505	+ 0.124	1014.2

as the difference between the observed in-plane lattice constant and that of the material as a free-standing layer. The presence or lack of CM was confirmed using cross-section TEM and X-ray reciprocal space analysis [12]. A summary of all results are presented in Table 1. The integrated intensity of the reciprocal space X-ray measurements is a measure of the strength of the composition modulation wave amplitude [9]. In Table 1, the X-ray intensity of zero value for samples EA0121 and EA0180 indicate that no CM was observed. However, for EA180, there is some evidence for CM on a very local scale, i.e. there appear to be uncorrelated fluctuations. A plot of the integrated X-ray intensity as a function of indium concentration is shown in Fig. 1. The smooth curve drawn through the experimental points is meant to be a guide for the eye and has no theoretical interpretation.

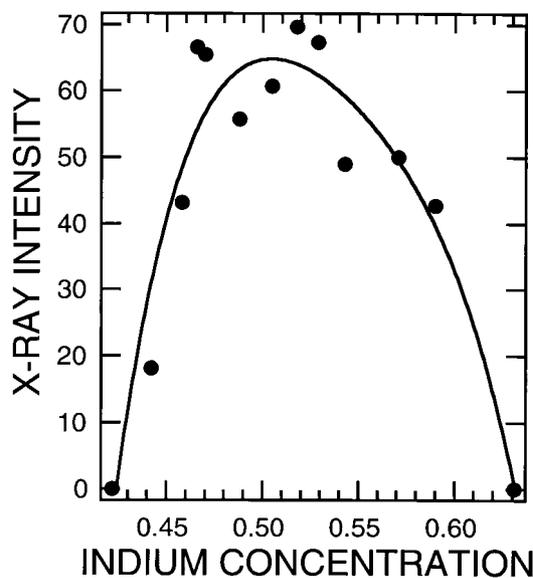


Fig. 1. Plot of the integrated X-ray intensity given as a function of the indium concentration, listed in Table 1. The smooth curve drawn through the data is provided as an aid to the eye.

The photoluminescence spectroscopy measurements were made at 4.0 K. The CM samples were attached to the end of a 100 μm -core-diameter optical fiber and placed in a liquid helium storage dewar. The PL measurements were made with an Argon-ion laser operating at 514.5 nm. The laser was injected into the optical fiber by means of an optical beam-splitter and the returning photoluminescence signal was directed to a 0.27-m, f14 optical monochromator and a IEEE488-based data acquisition system. Typical laser power densities on the sample were of the order of 1 W/cm^2 and a NORTH COAST EO-817 germanium detector was used to record the infrared energy photons. The 4-K luminescence peak energy for each sample is tabulated in Table 1. The low temperature PL spectrum for sample EA0184 is shown in Fig. 2 where the main PL peak near 1000 meV is that from the indium-rich (lowest energy) bandgap portion of the

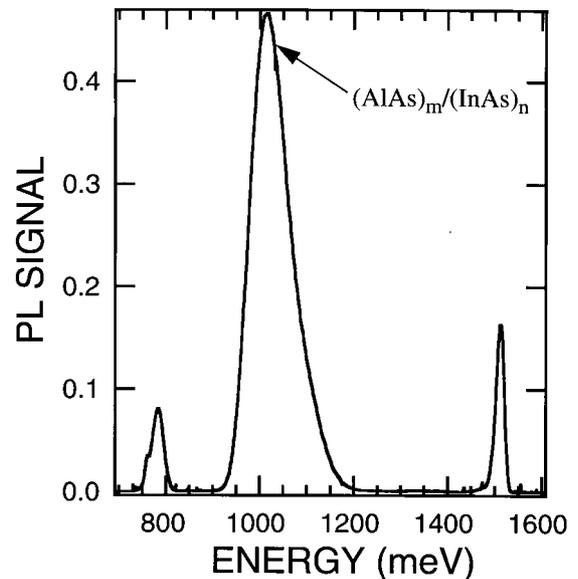


Fig. 2. PL spectrum for sample EA0184 at 4 K. The PL peak near 1000 meV is from the CM layer of the sample. The high and low energy PL peaks are, respectively, from the InAlAs buffer and the InGaAs cap layer.

(AlAs)_m/(InAs)_n SPS CM wave. The high energy peak near 1500 meV is from the nominally lattice-matched InAlAs buffer layer, while the PL peak at 800 meV is from the InGaAs cap layer. The line shape or linewidth of the CM PL spectrum will not be discussed here, but undoubtedly, contributions from a combination of residual strain and varying (inhomogeneous) indium concentration in the CM region are important.

2. Discussion

Fig. 3 is plot of the PL energy data given in Table 1 as a function of the indium concentration. Also shown is the corresponding concentration dependence of the bandgap energies for unstrained (dashed line) and strained (solid line) In_xAl_{1-x}As alloy on InP. The concentration dependence for unstrained In_xAl_{1-x}As bandgap energy $E^U(X)$ at 4 K is given in meV by [13]

$$E^U(X) = 3110 - 3395X + 725X^2, \quad (1)$$

where X is the indium concentration. In order to make meaningful comparison to the strained (AlAs)_m/(InAs)_n SPS structures, the effect on the bandgap energy by the coherent biaxial strain on coherently strained In_xAl_{1-x}As alloy must be considered and is easily calculated with the result

$$E^S(X) = E^U(X) + 2a \frac{C_{11} - C_{12}}{C_{11}} \varepsilon_{xx} - \left[2b \frac{C_{11} + C_{12}}{C_{11}} \varepsilon_{xx} \right] \quad (2)$$

where corrections due to the spin-orbit induced split-off valence-band have been ignored. In Eq. (2), a and b , are, respectively, the volume and biaxial deformation potentials, C_{11} , and C_{12} are the elastic constants, and is the in-plane strain. Because the biaxial strain splits the degenerate alloy valence bands, the bandgap energy is always decreased by the biaxial term, independent of which valence-band is the ground state, i.e. when the lattice is in tension or compression, there is a reversal of the symmetry of the valence-band ground state, but the bandgap energy is

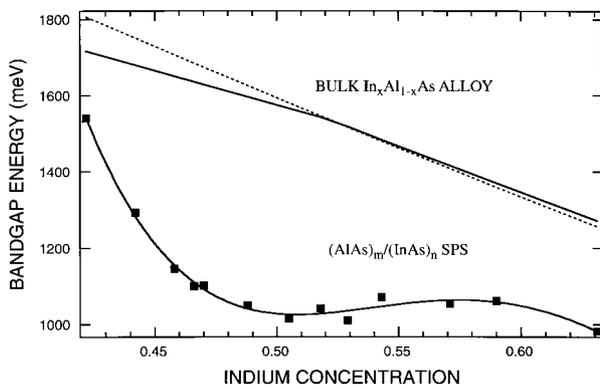


Fig. 3. CM bandgap energy versus In concentration. The bulk In_xAl_{1-x}As bandgap energy for coherently strained (solid) and unstrained (dashed) limits is also shown.

Table 2
Physical parameters for AlAs and InAs

Physical property	AlAs	InAs
Lattice constant (Å), $d_{\text{InP}} \equiv 5.8686 \text{ \AA}$	5.6613	6.0584
Elastic constant C_{11} (10^{11} dynes/cm ²)	11.63	8.663
Elastic constant C_{12} (10^{11} dynes/cm ²)	5.76	4.848
Deformation potential, a (eV)	- 10.2	- 6.26
Deformation potential, b (eV)	- 1.5	- 1.8

decreased. Because the PL transition is between the two lowest energy states, conduction and valence-band, we use the absolute function in the third term of Eq. (2) to account for the biaxial strain reduction of the bandgap energy. The physical parameters used in this paper for AlAs and InAs are listed in Table 2. The in-plane strain ε_{xx} (or lattice mismatch), tabulated in Table 1, is defined in terms of the lattice constants d_{InAlAs} and d_{InP} by

$$\varepsilon_{xx} = \frac{d_{\text{InAlAs}} - d_{\text{InP}}}{d_{\text{InAlAs}}} \quad (3)$$

We now calculate the bandgap reduction for the indium-rich part (AlAs)_m/(InAs)_n SPS CM wave. This is accomplished by subtracting the observed PL bandgap energy shown in Fig 3 (and also tabulated in Table 1) from the calculated In_xAl_{1-x}As strained bandgap energy (Eq. (2)) for each indium concentration.

Fig. 4 shows the bandgap energy reduction for all of the samples listed in Table 1. Also shown (dashed line) is the X-ray intensity data shown Fig 1. As can be seen in the figure, there is a strong correlation between the X-ray intensity data (Fig. 1) and the bandgap energy reduction, i.e. the maximum reduction occurs for those samples with the largest X-ray intensities. As discussed by Zhang and Mascarenhas [14], there are two contributions to the bandgap energy reduction. The first is a structural effect due to the (100)-oriented SPS and the second is that due to CM and may be as large as 400 meV for our samples. For no CM, SPS monolayers of AlAs and InAs result in a CuAu-type structure and it is estimated [14] that the bandgap reduction is about 100 meV. For sample EA0121 (far left side of Fig. 4) this 100 meV reduction is reasonable with the observed reduction of about 175 meV, especially in view of the fact that EA0121 is not a monolayer SPS ($n = 1.60$, $m = 2.18$). However, the same conclusion does not hold for the indium-rich EA0180 (no CM) where the reduction is ~ 300 meV. Zhang and Mascarenhas [14] also show that the that large CM diminishes the CuAu-order and hence the energy reduction. Twosten [15] has performed scanning TEM measurements on sample EA0184 and finds that the maximum indium concentration in the CM wave is $x = 0.76$. The energy for bulk In_{0.76}Al_{0.24}As is somewhat lower than the bandgap energy for EA0184 suggesting that the reduction due to the CuAu-ordering is negligible, but confirming the presence of large

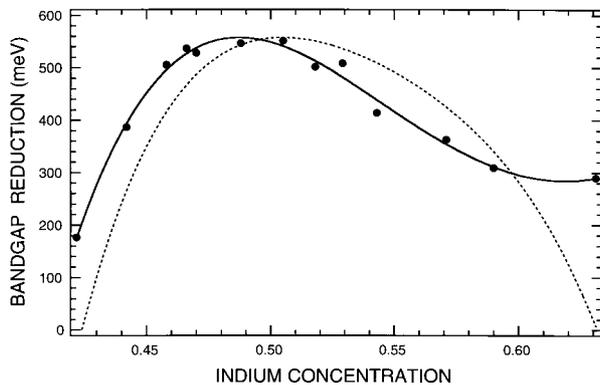


Fig. 4. Bandgap reduction energy versus indium concentration. The solid line drawn is a smooth curve to aid the eye. The dashed line is the corresponding X-ray intensity versus indium curve shown in Fig. 1.

CM. This slightly higher PL energy suggests quantum confinement may play a role.

3. Conclusions

We have presented low temperature PL data for a large number of $(\text{AlAs})_m/(\text{InAs})_n$ SPS structures on InP with varying degrees of CM. We find that when there is evidence for strong CM, there is a large bandgap energy reduction in the PL energy. These results compare favorably with the recent theoretical treatment for bandgap reduction by Zhang and Mascarenhas [14].

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